Supporting Information

A Combined Experimental and Theoretical Approach Revealing Direct Mechanism for Bifunctional Water Splitting on Doped Copper Phosphide

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Computational Details:

First principles calculations were carried out using the projector-augmented wave (PAW)^{S1} method, as employed in the Vienna Ab initio Simulation Package (VASP).^{S2} The generalized gradient approximation of Perdew-Burke-Ernzerhof (GGA-PBE)^{S3,S4} was used for describing the exchange-correlation potential. A plane wave basis set was used for an energy cut-off of 470 eV. The energy criteria for self-consistent calculations were set to 10^{-4} eV between two successive steps, and the atomic forces of all the systems were set to less than 0.01 eVÅ⁻¹ without any symmetry constraints. Only ions were relaxed for the bulk calculations with experimental cell parameters, whereas both ions and cell parameters were relaxed for slab calculations. A vacuum of ~15 Å was employed in the *z*-directions to avoid interactions between the periodic layers. Slab calculations were carried out in a 2×2 supercell geometry in the periodic *xy*-plane, and the Brillouin zone of the supercell was sampled with a set of $3 \times 3 \times 1$ Gamma centered k-point grids for geometry optimization. Symmetric slabs were constructed across the vacuum direction considering 144 and 120 atoms for Cu- and CuP-terminations, respectively. We used $6 \times 6 \times 6$ Gamma centered k-point grids for density of state calculations of the bulk structures. Spin polarized calculations were performed for the calculations of Fe-doped systems.

Surface energy of the slabs (E_{sur}) was calculated using the following equation:

$$E_{sur} = (E_{slab} - E_{bulk})/A_{slab}$$

where E_{slab} is the total energy of the pristine/Fe-doped slabs, E_{bulk} is the total energy of the bulk systems containing the same number of atoms in the slabs, and A_{slab} is the total surface area of the slabs.

We constructed both Cu-terminated and CuP-terminated surfaces. Based on the calculated surface energy, the CuP-terminated surface is more stable (Table S4); therefore, we studied the adsorption behavior of the reaction intermediates utilizing the CuP-terminated surface.

The adsorption energies (E_{ad}) of all the possible intermediates were calculated using the following equation:

$$E_{ad} = E_{slab-adsorbate} - (E_{slab} + E_{adsorbate})$$

where $E_{slab-adsorbate}$ represents the total energy of the surface with adsorbed species, E_{slab} and $E_{adsorbate}$ represent the total energy of the periodic surface and adsorbed intermediates (*O, *OH, *OOH and *H), respectively.

The ΔZPE correction for adsorbed intermediates was taken from the vibrational frequency calculation by density functional perturbation theory (DFPT). This was done using a selective

dynamics approach, where the coordinates of Cu₃P slab atoms were frozen during the frequency calculations. Furthermore, we did not consider the entropy (Δ S) contribution, as it is negligible for adsorbed intermediates.^{S5} The Δ S values for the free gaseous molecules were taken from the NIST database.^{S6} As the GGA-DFT method cannot accurately calculate the O₂ bond energy, we took the O₂ bond energy associated with water formation (2H₂+O₂=2H₂O), which is 4.92 eV.^{S5,S7,S8} Δ G_{pH} is the correction of the H⁺ free energy and depends on whether the reaction under acidic or basic condition. Δ G_{pH} = $-k_BT\ln[H^+] = pH \times k_BT\ln 10$, where k_B is the Boltzmann constant, *T* is the temperature and pH is equal to 14 for alkaline medium. The free energy of OH⁻ was derived as G_{OH-} = G_{H2O(1)} - G_{H+}. The free energy for gas phase water is calculated at 0.035 bars, because this is the equilibrium pressure in contact with liquid water at 298 K. At these conditions, the free energy of gas phase water is equal to the free energy of liquid water.^{S9}

Materials Characterization:

Wide-angle X-ray diffraction patterns were collected using a multipurpose attachment from SmartLab, RIGAKU. The measurements were taken at a 20 scan range of 10–90°, scan speed of 2.4°/min, and step size of 0.01 Å, using CuK_a radiation to identify the phases. The exterior morphology, elemental mapping and EDXS were analyzed using a Magellan 400 scanning electron microscope (SEM). Transmission electron microscopy (TEM) was carried out using field emission transmission electron microscopy (FE-TEM; Tecnai TF30 ST). The TEM samples were prepared by drop casting the ethanol suspension of each respective catalyst on a 300-mesh copper grid. Xray photoelectron spectroscopy (XPS) was carried out using a Thermo VG Scientific Sigma Probe system equipped with an Al-K α X-ray source (1486.3 eV) with an energy resolution of 0.47 eV full width at half maximum under ultrahigh vacuum conditions of 10⁻¹⁰ Torr. FM40 Contact Angle Measuring Instrument Easydrop was used to measure the contact angle on carbon fiber surface. A Monochrome interline CCD, 25/30 fps, 752×582 px camera was used during analysis.



Fig. S1. (a) Wide-angle powder XRD pattern of post hydrothermal product which is isolated as pure malachite (precursor for Fe doped Cu_3P) (b) Fe 2p XPS profile of post hydrothermal product and (c) wide-angle XRD pattern of different electrocatalysts prepared with different Fe doping.



Fig. S2 HRTEM shows the (110) plane lattice spacing of (a) Cu₃P and (b) Fe-doped Cu₃P.



Fig. S3. SEM images of the (a) $Cu_{2.95}F_{0.05}P$ (b) $Cu_{2.75}F_{0.25}P$ and (c) $Cu_{2.46}F_{0.54}P$. It clearly shows that the size of the nanocucurbits decrease with increased Fe dosing amount, resulting in a more hydrophilic surface.



Fig. S4. SEM-EDX spectra of various Fe doped Cu₃P catalysts. Based on the atomic percentage, the empirical formula was presented.



Fig. S5. Cu 2p XPS spectra of pristine and Fe doped Cu₃P (Cu_{2.75}F_{0.25}P)



Fig. S6. Fe 2p XPS profile of Fe doped Cu₃P (Cu_{2.75}Fe_{0.25}P).



Fig. S7. P 2p XPS profile of $Cu_{2.75}Fe_{0.25}P$ at different stages of the reaction.



Fig. S8. Cyclic voltammograms recorded for the doped and undoped Cu₃P within a non-faradaic region at various scan rates (mVs⁻¹) for determining the double layer capacitance. The total output current can be expressed as $J = J_f + C_{dl}$ (dE/dt), where J_f represents the Faradaic current, C_{dl} is double layer capacitance, (dE/dt) is scan rate. At non-faradaic zone, from the difference of anodic and cathodic current density with the function of scan rate resulted a linear curve. The determination of the slope value corresponds to the C_{dl} of the respective electrode. The linear curve and the slope value is mentioned in manuscript (Fig. 3c). The C_{dl} of each electrode serves as an estimate of the effective electrochemically active surface area of the solid–liquid interface. The calculated C_{dl} values for the Cu₃P, Cu_{2.95}Fe_{0.05}P, Cu_{2.75}Fe_{0.25}P, Cu_{2.46}Fe_{0.54}P is 1.2 μ F cm⁻², 1.4 μ F cm⁻², 5 μ F cm⁻², and 3.1 μ F cm⁻² respectively.



Fig. S9. Optimized structures for the (0001) slabs of (a) Cu-ter, (b) CuP-ter, (c) CuFe-ter and (d) CuFeP-ter

Catalyst	Cell parameter	Angles	Reitveld	% of Cu phase
-			refinement	_
			parameter	
Cu ₃ P	a = b = 6.9593 and c	$\alpha = \beta = 90^{\circ} \gamma = 120^{\circ}$	R _w is 10.52%	16.4%
5	= 7.143		(sigma 1.55)	
$Cu_{275}Fe_{025}P$	a = b = 6.9581 and $c =$	$\alpha = \beta = 90^{\circ} \gamma = 120^{\circ}$	R _w is 7.14%	43.2%
2.75 0.25	7.140		(sigma 1.16)	

Table S1. Crystal cell parameter measured using wide angle XRD.

Table S2. Amount of Fe content after doping in Cu₃P.

Theoretical (mol%/wt%)	ICP-AES (wt%)	SEM EDSX (wt%/atomic
		composition)
2/1.8	1.5 ± 0.05	$1.6 \pm 0.05 (Cu_{2.95}Fe_{0.05}P)$
10/8.9	7.4 ± 0.1	$7.9 \pm 0.05 (Cu_{2.75}Fe_{0.25}P)$
20/19	17.6 ± 0.3	$16.5 \pm 0.05 (Cu_{2.46}Fe_{0.54}P)$

Fable S3. Surface Energy (meV/A)	A^2) for the different terminat	ions
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Systems	Pristine	Fe-doped
Cu/Fe-terminated	25	26
CuP/FeP-terminated	3	6

Table S4. Adsorption energies (eV) for all the possible adsorption intermediates in pristine and Fe-doped surfaces

Reaction intermediates	Pristine	Fe-doped	
*O (Cu-P bridge)	-4.40	-4.45	
*O (Fe-P bridge)	-	-4.89	
*O (Cu-top)	-2.09	-3.95	
*O (Fe-top)	-	-4.55	
*O (P-top)	-4.28	Not stable. Move to bridge site	
*O (fcc)	Not stable. Move to bridge site	Not stable. Move to bridge site	
*OH (Cu-P bridge)	-2.31	-2.09	
*OH (Fe-P bridge)	-	-2.41	
*OH (Cu-top)	-1.92	-1.62	
*OH (Fe-top)	-	-3.02	
*OH (P-top)	-2.39	-2.35	
*OOH (Cu-P bridge)	-2.93	Not stable. Move to top site	
*OOH (Fe-P bridge)	-	Not stable. Move to top site	
*OOH (Cu top)	-2.86	-2.77	
*OOH (Fe top)	-	-3.93	
*OOH (P top)	-3.13	-3.00	
*H (Cu-P bridge)	-2.05	-1.68	

*H (Fe-P bridge)	-	-1.57
*H (Cu top)	-1.52	-1.50
*H (Fe top)	-	-2.23
*H (P top)	-2.18	-1.35

 Table S5 Activity comparison among different earth abundant bifunctional catalyst for overall water splitting.

Sl No	Catalyst	Electrolyt	Current	Catalyst	Reference
		e/process	density/potential	amount	
1.	Ordered CoMn/N doped C superlattice structure	1 M KOH/OW S	100 mA cm-2 at 1.78 V of cell voltage	2.0 mg·cm ⁻²	J. Am. Chem. Soc., 2015, 137 , 14305–14312
2.	Carbon Nanotube- Supported MoSe ₂ Holey Flake:Mo ₂ C Ball Hybrids	1 M KOH/bifu nctional	0.089 V and 0.241 V for HER and OER respectively	0.2 mg cm ⁻ ² .	<i>ACS Nano</i> , 2019, 13 , 3162–3176
3.	NiFePS on nickel foam	1.0 M KOH/OW S	50 mA cm ⁻² at 1.9 V		<i>ACS Nano</i> , 2017, 11 , 10303–10312
4.	Epitaxial Dinickel Phosphide to 2D Nickel thiophosphate	1.0 M KOH/OW S	100 mA cm ⁻² at 1.74 V of cell voltage	1.0 mg cm- ²	<i>ACS Nano</i> , 2019, 13 , 7975–7984
5.	NiSe Nanowire Film Supported on Nickel Foam	1.0 M KOH/OW S	50 mA cm ⁻² at 1.9 V of cell voltage	2.8 mg cm ⁻²	<i>Angew. Chem.</i> <i>Int. Ed.</i> , 2015, 54 , 9351– 9355
6.	MoS ₂ /Ni ₃ S ₂ Heter ostructures	1.0 M KOH/OW S	10 mA cm ⁻² at 1.56 V of cell voltage	3 mg cm ⁻²	<i>Angew. Chem.</i> <i>Int. Ed.</i> , 2016, 55 , 6702– 6707
7.	High-Index Faceted Ni ₃ S ₂ Nanosheet on nickel foam	1 M NaOH/O WS	20 mA cm ⁻² at 1.53 V of cell voltage	1.6 mg cm ⁻²	J. Am. Chem. Soc., 2015, 137 , 14023–14026
8.	Nitrogen-doped tungsten carbide nanoarray	1 M H ₂ SO ₄ /O WS	20 mA cm ⁻² at 1.65 V of cell voltage	10 mg cm ⁻²	Nat. Commun., 2018, 9, 924
9.	Cu nanowires shelled with NiFe layered double hydroxide	1 M KOH/OW S	100 mA cm ⁻² at 1.7 V of cell voltage	2.2 mg cm ⁻²	Energy Environ. Sci., 2017, 10 , 1820-1827

10.	Ultrathin	1.0 м КО	100 mA cm ⁻² at 1.94	0.16 mg	Adv. Mater.,
	Feroxyhyte	H/OWS	V of cell voltage	cm ⁻²	2018, 30 ,
	Nanosheets				1803144
11.	Co ₃ O ₄ @3D	1 M	100 mA cm ⁻² at 1.65	0.4 mg cm^{-2}	ACS Nano,
	Ti ₃ C ₂ -MXene	KOH/OW	V of cell voltage		2018, 12 ,
		S			8017-8028
12.	Cu ₉ S₅/NF	1 M KOH/	100 mA cm ⁻² at 1.6 V	0.6 mg cm^{-2}	Chem.: Asia.
		OER	(vs RHE)		<i>J.</i> , 2020, 15 ,
					852-859.
13.	CuSe/NF	1 M KOH/	$10 \text{ mA cm}^{-2} \text{ at } 1.72 \text{ V}$		ChemSusChe
		OWS	of cell voltage		<i>m</i> , 2020, 13 ,
					3222-3229

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